## **ELECTRONIC INFORMATION DISCLOSURE STATEMENT**

## Electronic Version v18

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Title of Invention

LOW-K INTERLEVEL DIELECTRIC LAYER (ILD) AND METHOD

**Application Number:** 

Confirmation Number:

First Named Applicant:

Matthew Angyal

Attorney Docket Number:

FIS920040049US1

Art Unit:

Examiner:

Search string:

(6528432 or 6436808 or 6483173).pn

## **US Patent Documents**

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
an	1	6528432	2003-03-04	Ngo, et al.			
a	2	6436808	2002-08-20	Ngo, et al.			
ah	3	6483173	2002-11-19	Li, et al.			

## Signature

Examiner Name	Date
andrituna	08/02/05